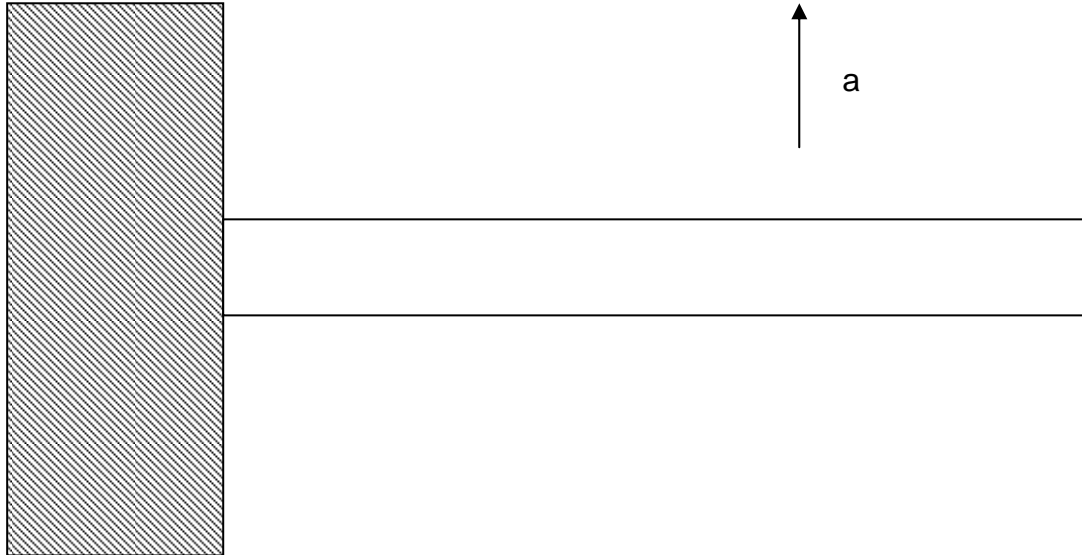


Exercise 4 for FYS4230 Microsystem modeling
Piezoresistors on a bending beam

A fixed–free beam experiences an acceleration $a=50g$ (g is the acceleration of gravity) so that it bends downwards.

Sideview:



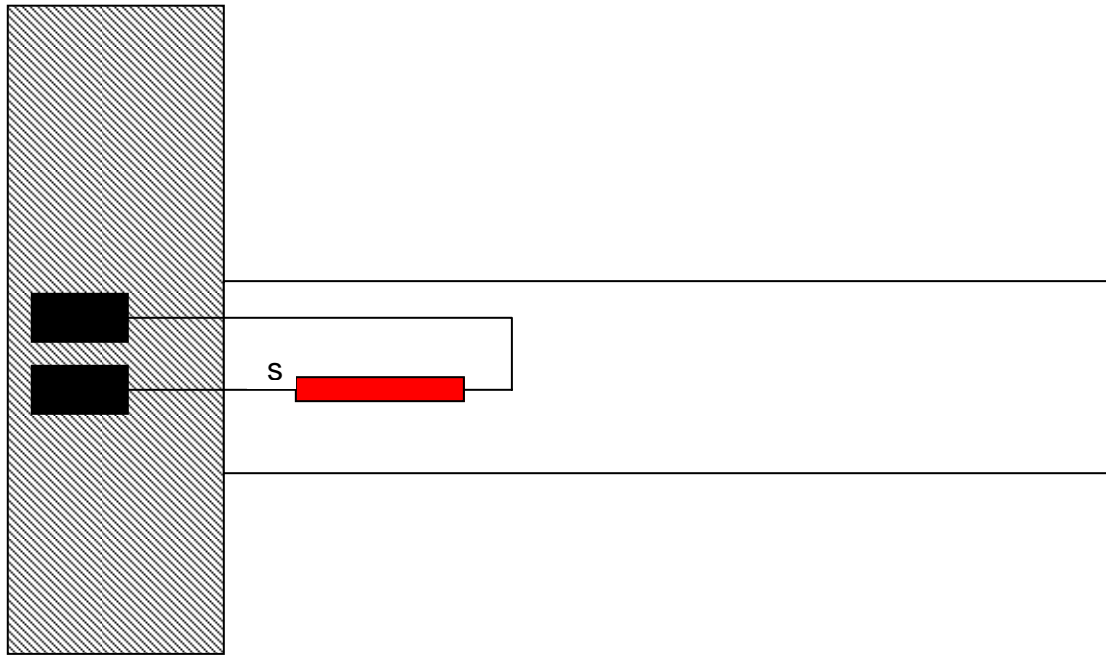
The dimensions of the beam: The length is $L=3\text{mm}$, the thickness is $h=8$ micrometers and the width $w=50$ micrometer. The normal stresses on normal sections of a beam were found in exercise 1 (the exercise about beam bending).

The beam itself is micromachined in an n-type, (100) silicon wafer. The beam is parallel to the $\langle 110 \rangle$ flat.

A p-type piezoresistor is implanted and diffused from the top side of the beam. The piezoresistor is 0.2 micrometer deep, 5 micrometer wide and 50 micrometer long. If the piezoresistor is parallel with the beam length direction

- a) Where would you place the piezoresistor in order to obtain a maximum sensitivity? Notation: the piezoresistor starts at a distance s from the beam end.

Top view, beam with piezoresistor, conductors and bonding pads:



- b) Explain why the mean value of the normal stress in the piezoresistor can be described by:

$$\bar{\sigma} = \frac{1}{10(\mu\text{m})^2} \int_{3.8\mu\text{m}}^{4\mu\text{m}} \int_{s\mu\text{m}}^{s+50\mu\text{m}} \frac{1}{2} z(x^2 - 2Lx + L^2) \frac{12 \cdot 50 \rho L b h g}{L b h^3} dx dz$$

Without calculating this integral, which value of the normal stress would you pick as an approximate mean value for the whole piezoresistor?

- c) The n-type beam is connected to the potential $V=0$. Should the potential of the p-type circuit be positive or negative relative to this voltage?
- d) The gauge factor for the piezoresistor is given by:

$$\frac{\Delta R}{R} = \pi_l \sigma_l + \pi_t \sigma_t$$

The resistivity of the piezoresistor is $7.8\Omega\text{-cm}$. Find the values for the longitudinal and transverse piezocoefficients. And then the gauge factor for the beam when it bends out with the acceleration.

- e) Suggest an alternative positioning of the piezoresistor (disregard space needed for conductor lines). Will the gauge factor increase or decrease?
- f) If you place two piezoresistors on the beam and connect them in a half-bridge in the optimal way, find an expression for the bridge output V_0 .

g) How would you suggest optimizing this piezoresistive accelerometer?
How could you improve the sensitivity?